

Mono Silane SiH₄

Features

■ Purity : 99.999%

Physical state : Gas (liquefied gas)

Appearance : Compressed liquefied gas in high-pressure gas cylinder

■ Boiling point : -112 °C

■ Melting point : -185 °C

■ Vapor pressure : 4080 kPa (-10 °C)

Applications

■ Specialty gas as an agent for Chemical Vapor Deposition(CVD) in semiconductor, LCD and Solar industries

Customers

■ Mitsui mono silane has been widely used among global leading semiconductor companies and Solar companies for decades